

# Ultrasensitive and ultrasensitive TEA sensor based on $\alpha$ - $\text{MoO}_3$ hierarchical nanostructures and the sensing mechanism

Lili Sui,<sup>ab</sup> Xiaoxiao Song,<sup>a</sup> Xiaoli Cheng,<sup>a</sup> Xianfa Zhang,<sup>a</sup> Yingming Xu,<sup>\*a</sup>

Shan Gao<sup>a</sup>, Ping Wang,<sup>ab</sup> Hui Zhao<sup>a</sup> and Lihua Huo<sup>\*a</sup>

<sup>a</sup> Key Laboratory of Functional Inorganic Material Chemistry, Ministry of Education.

School of Chemistry and Materials Science, Heilongjiang University,

Harbin, 150080, P. R. China

<sup>b</sup> College of Chemistry and Chemical Engineering, Qiqihar University, Qiqihar  
161006, P. R. China.

Tel / Fax: (+86) 451 8660 8426

E-mail address: E-mail: [lhhuo68@yahoo.com](mailto:lhhuo68@yahoo.com)

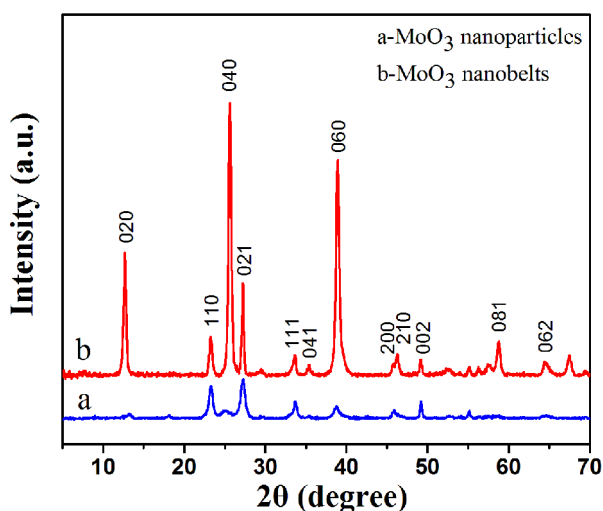


Fig. S1 XRD patterns of the products prepared in a mixture of acetic acid (33 mL) and distilled water (2 mL) at 150 °C for 5 min (a) and 30 min (b).

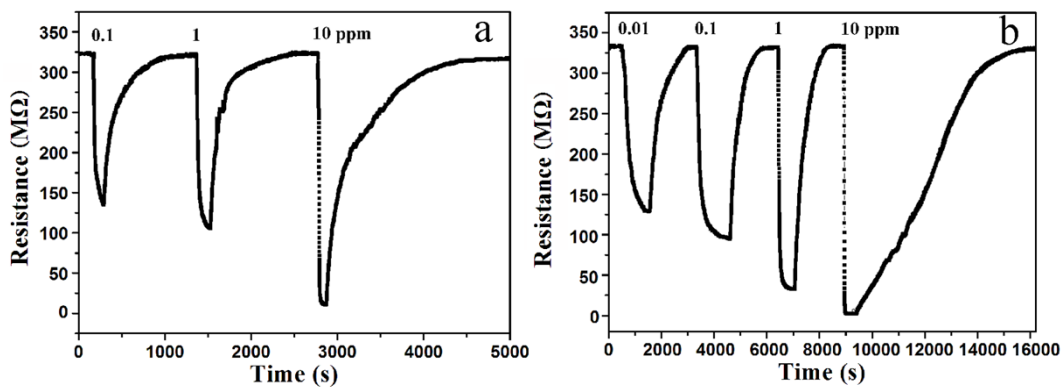


Fig. S2 Sensing transients of Mo-NP (a) and Mo-NB (b) sensors to different concentrations of TEA at the working temperature of 170 °C.

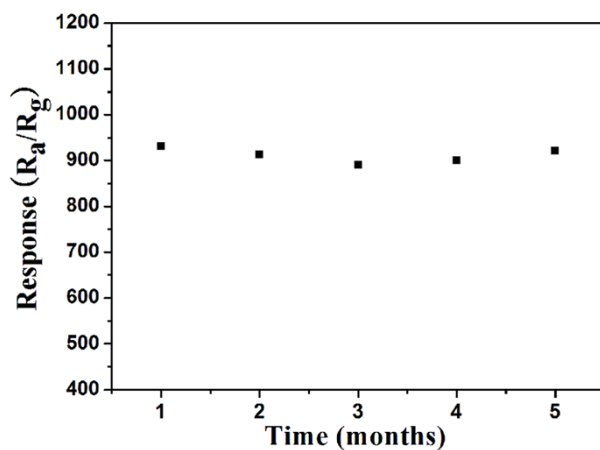


Fig. S3 Variations in response of the Mo-FL sensor to 10 ppm TEA at 170 °C measured in ambient condition of  $25 \pm 5$  RH% after storage in air for different time periods.

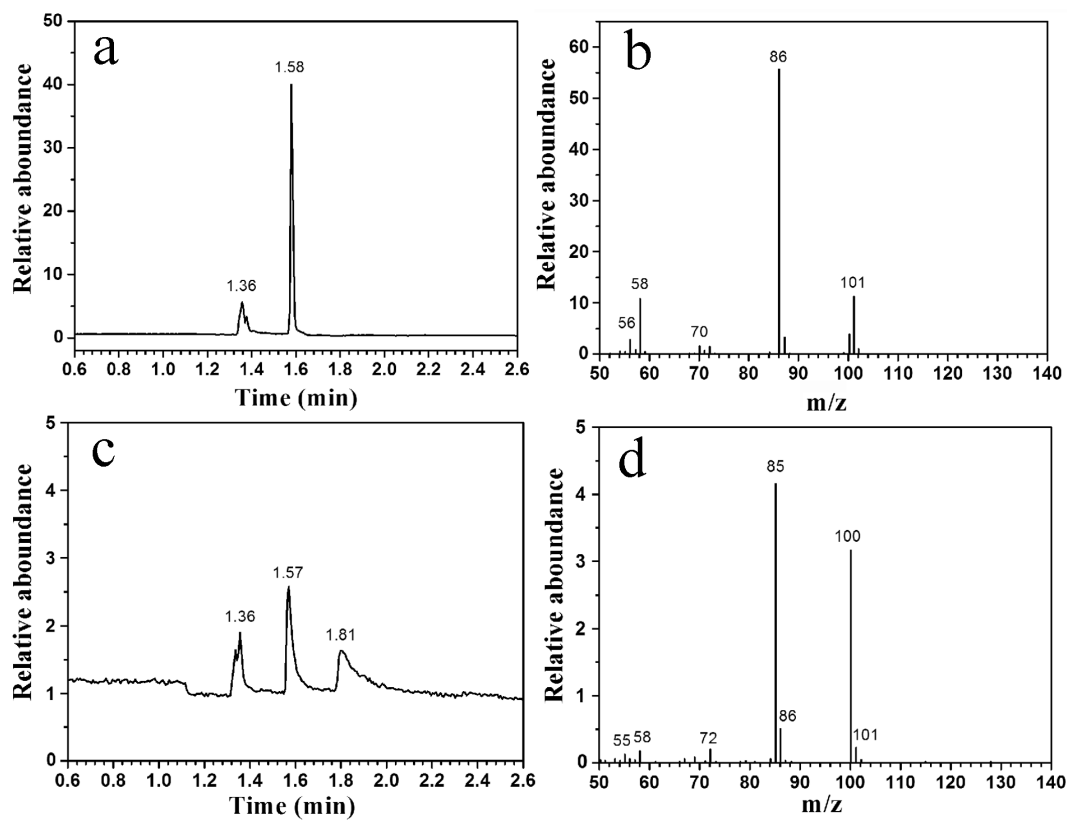


Fig. S4 Gas chromatograms (a, c) and Mass spectra (b, d) of TEA (a and b) and the intermediate gaseous product after the  $\alpha$ -MoO<sub>3</sub> flowers sensor exposure to TEA (c and d).